

Nano-R

Fabrication and Reliability of Nanodevices based on 0D, 1D, & 2D Nanomaterials

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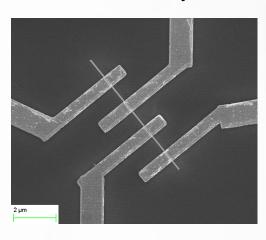


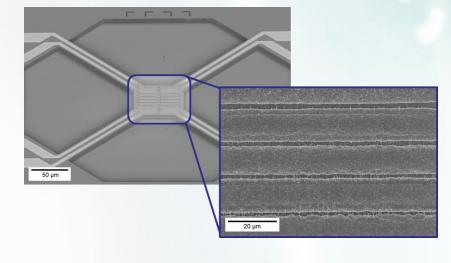
Challenges and objectives

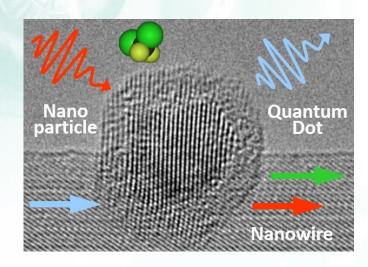
- Novel nanomaterials enable entirely new applications (Graphene, MoS₂, nanowires, quantum dots...)
- How to fabricate and integrate such nanomaterials on CMOS based devices?
- How to fabricate new "Si-less" nanodevices ?
- How to analyse the nanodevices?

Technical goals

- Fabrication and integration technologies
- Lot of reliability issues !!!
- E.g. electrical contacts
- Novel analysis tools and technologies from macro to nano along production chain







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Partners

- Materials Center Leoben (MCL)
- University of Oxford
- KTH Stockholm
- ETH Zürich
- EVGroup
- Etc.
- Which call....?

Contact

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Economical impact (optional)

- Entirely new sensor devices
- Entirely new light emitting devices
- Energy storage & energy harvesting
- Ultra low power devices for IoT and wearables

Expected Duration / budget (optional)

• 48 months, XXXX k€